

“High resolution electron microscopy and X-ray photoelectron spectroscopy studies of heteroepitaxial Si_xGe_{1-x} alloys produced through laser induced processing”. Frangis N, van Landuyt J, Lartiprete R, Martelli S, Borsella E, Chiussi S, Castro J, Leon B, Applied physics letters **72**, 2877 (1998). <http://doi.org/10.1063/1.121487>